

Abstract of (1)

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 09-024050
 (43)Date of publication of application : 28.01.1997

(51)Int.CI. A61B 17/04
 A61L 17/00

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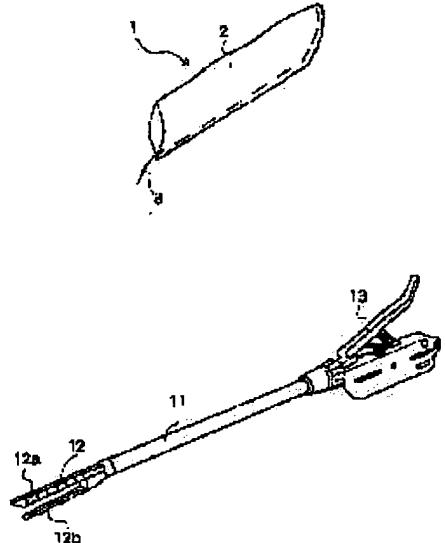
(30)Priority
 Priority number : 07109834 Priority date : 08.05.1995 Priority country : JP

(54) SUTURE MATERIAL FOR MEDICAL TREATMENT

(57)Abstract:

PURPOSE: To prevent the occurrence of an inconvenience due to offset or rotation at the time of inserting an automatically suturing unit by sewing a suture material like a bag with the forward end closed, and mounting the sewn material on the automatically suturing unit having a stable line, regarding a medical treatment suture material sewn with the resected part or the like of a bio-tissue.

CONSTITUTION: A medical treatment suture material 1 is formed out of a single main suture material 2 made, for example, of a felt of absorptive polyglycolic acid and sewn like a bag with the forward end closed. In other words, the material 2 has length nearly equal to the length of the device part of an automatically suturing unit, and is folded double. Then, the material 2 is stitched with a stitching thread 3 along one breadthwise side thereof. For the thread 3, a monofilament is used for the convenience of extracting the stitches. This type of medial treatment suture material is formed to have a freely opened and closed stitching part 12 at the end of a shaft 11 and fitted to an automatically suturing unit having an operation part 13 at the base end thereof for holding and operation purposes.



LEGAL STATUS

[Date of request for examination] 10.04.2002

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the examiner's decision of rejection or

[application converted registration]
[Date of final disposal for application]
[Patent number]
[Date of registration]
[Number of appeal against examiner's decision
of rejection]
[Date of requesting appeal against examiner's
decision of rejection]
[Date of extinction of right]

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